



Assembled Chemical Weapons Assessment Program

Chemical Agent Air Monitoring Concepts

**Mark Ditmore
Science Applications International
Corporation (SAIC)**

2001-02-07, Denver, CO

MD-1



Purpose of Chemical Agent Air Monitoring

- ◆ Provides protection to the worker, environment, and general public
- ◆ Alerts the operator to potential processing problems
- ◆ Integrates with automatic waste feed cut-offs
- ◆ Provides historical information

2001-02-07, Denver, CO

MD-2

Current Monitoring Technologies

- ◆ Near-real time (NRT) monitoring devices
 - Automated devices placed throughout the facility
- ◆ Depot Area Air Monitoring System
 - Automated sample collection system collocated with Near-real time systems and located at other areas within the plant and facility boundary for historical documentation

2001-02-07, Denver, CO

MD-3

Near Real-Time Monitoring Technologies

- ◆ Near-Real Time Monitoring Devices
 - ACAMS
 - MINICAMS
 - Agilent 6850
- ◆ Designed to be robust and meet the U.S. Army requirement of providing a response within 15-minutes
- ◆ Detects HD at 0.0006 mg/m³



ACAMS



MINICAMS



Agilent 6850

2001-02-07, Denver, CO

MD-4



Near Real-Time Monitoring Technologies (Concluded)

- ◆ Provides audible and visual alarms
- ◆ Real-time data recordings
- ◆ Coupled with Depot Area Monitoring System (DAAMS) for confirmation
- ◆ Monitors large range of monitoring levels in various atmospheres:
 - Toxic area monitoring (process indicator)
 - Non-toxic areas (worker protection)
 - Stack monitoring (high temperature and moisture)

2001-02-07, Denver, CO

MD-5



Depot Area Air Monitoring System (DAAMS) Technology

- ◆ Uses porous solid sorbent technology (Tenax)
- ◆ Tenax provides:
 - High affinity for HD
 - High thermal stability
 - Low sorbent bleed and excellent desorption capabilities
- ◆ Functions both as historical (Depot Area Air Monitoring System (DAAMS) only) and confirmation (NRT/DAAMS) systems
- ◆ Capable of detecting a wide range of monitoring levels (General Population Limit [GPL] to Allowable Stack Concentration [ASC] and higher)
- ◆ Multiple samples capable of being collected (redundant)



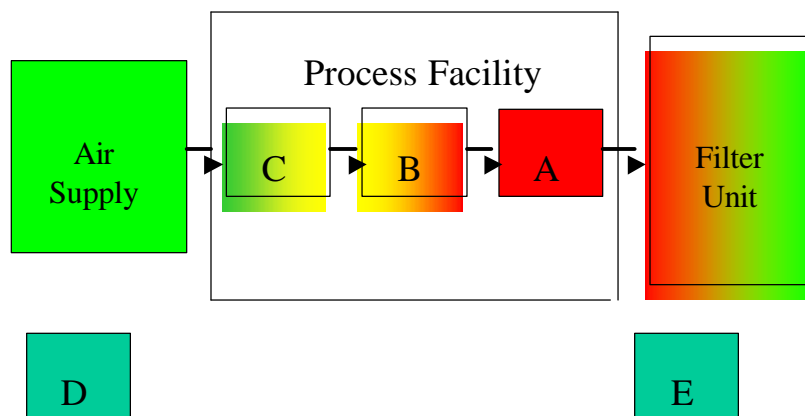
2001-02-07, Denver, CO

MD-6

General Monitoring Concept

- ◆ Locate sample collection points at areas where, if present, chemical agent will most likely be detected.
- ◆ Smoke test or Sulfur Hexa-fluoride (SF₆) is used to determine optimal location(s) within facility.
- ◆ Air modeling used to located perimeter (facility boundary) sampling points.
- ◆ Types and levels of monitoring are tied to ventilation category classifications
 - Category A
 - Category B
 - Category C
 - Category D
 - Category E

Ventilation Categories





Category “A” Areas

- ◆ Toxic process areas under negative pressure
 - Liquid and vapor contamination
- ◆ Monitoring Type (Near-real Time only)
 - Known contamination present
 - No Near-real Time (NRT) confirmation needed
 - Process indicator
- ◆ Monitoring Level
 - Maximum Permissible Level (100 mg/m³)
 - Personnel in Occupational Safety and Health Administration (OSHA) Level A PPE

2001-02-07, Denver, CO

MD-9



Category “B” Areas

- ◆ Toxic processing areas under negative pressure
 - Usually vapor contamination only
- ◆ Monitoring Type (Near-real Time only)
 - Known contamination present
 - No Near-real Time confirmation needed
 - Process indicator
- ◆ Monitoring Level
 - Maximum Permissible Level (100 mg/m³) or Gross Level Detection (0.2 mg/m³)
 - Personnel in Occupational Health and Safety Administration (OSHA) Level A, B, or C PPE

2001-02-07, Denver, CO

MD-10



Category “C” Areas

- ◆ Work area under negative pressure
 - Low agent vapor hazard
- ◆ Monitoring Type (Near-real Time with Depot Area Air Monitoring System)
 - Worker protection
 - Near-real Time confirmation needed
 - Historical documentation
- ◆ Monitoring Level
 - Time Weighted Average (0.003 mg/m³)
 - Personnel in Occupational Health and Safety Administration (OSHA) Level D PPE

2001-02-07, Denver, CO

MD-11



Category “D” Areas

- ◆ Work area under ambient pressure
 - Low agent vapor hazard
- ◆ Monitoring Type (Depot Area Air Monitoring only)
 - Historical documentation
- ◆ Monitoring Level
 - Time Weighted Average (0.003 mg/m³)

2001-02-07, Denver, CO

MD-12



Category “E” Areas

- ◆ Work area under positive pressure
 - Negligible vapor hazard
- ◆ Monitoring Type (Depot Area Air Monitoring System only)
 - Historical documentation
- ◆ Monitoring Level
 - Time Weighted Average (0.003 mg/m³)



Emission Source Monitoring

- ◆ Emission Source Points:
 - Carbon filters (midbeds and stacks)
 - Depot storage areas
- ◆ Depot storage area monitoring is the responsibility of the Depot



Process Stack Monitoring

- ◆ Monitored with Redundant Near-real Time systems with collocated Depot Area Air Monitoring System
 - 2-Near-real Time systems 50 percent offset from each other
 - 1-Near-real Time system is a backup for the 2-offset systems
- ◆ Monitoring level
 - Allowable Stack Concentration (0.03 mg/m³)
- ◆ Integrated into the automatic waste feed cut-off

2001-02-07, Denver, CO

MD-15



Carbon Filter Monitoring

- ◆ Selected midbeds and stacks are monitored
- ◆ Monitoring Type(s)
 - Near-real Time and Depot Area Air Monitoring System
- ◆ Monitoring Level
 - Time Weighted average (midbeds and stack)

2001-02-07, Denver, CO

MD-16



Perimeter Monitoring

- ◆ Located at strategic predetermined points around the facility boundary (air modeling based)
- ◆ Monitoring type:
 - Depot Area Air Monitoring System only
- ◆ Monitoring level:
 - General Population Limit (0.0001 mg/m³)

2001-02-07, Denver, CO

MD-17



Additional Monitoring

- ◆ Additional monitoring locations may be established:
 - Process monitors (e.g. ducts, reactors, etc.)
 - Emergency response (mobile Near-real Time systems)
 - XXX certification
- ◆ Monitoring levels may vary depending on the need:
 - Engineering control level for process situations (approx 50 Time Weighted Average [TWA])
 - Time Weighted Average [TWA] for emergency response and XXX certification

2001-02-07, Denver, CO

MD-18